

#2 *B. J. Hopkins*
8/11/99

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Schultz et al.
Serial No: Not Yet Assigned
For: An Illumination System Particularly For EUV
Lithography
Filed: Concurrently Herewith
Examiner: Not Yet Assigned
Art Unit: Not Yet Assigned Docket No.: 637.0001USU

PRELIMINARY AMENDMENT

Box: Patent Application
Assistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

Preliminary to examination, please amend the above-noted
patent application as follows:

IN THE CLAIMS

Please amend the claims as follows:

Cancel claims 1 through 52.

Add new claims 53 through 106 as follows:

53. An illumination system for wavelengths ≤ 193 nm, comprising:
- a light source having an illumination in a predetermined
surface;

1
a
cont.